

Stanford



Bhawani Shankar

Postdoctoral Scholar, Electrical Engineering

Bio

PROFESSIONAL EDUCATION

- Ph.D, Indian Institute of Science (IISc), Bangalore , GaN Power Device Reliability (2019)
- M.E, Birla Institute of Technology and Science (BITS), Pilani , Power Electronics and Drives (2013)
- B.E, Jai Narain Vyas University, Jodhpur , Electronics Engineering (2011)

STANFORD ADVISORS

- Srabanti Chowdhury, Postdoctoral Faculty Sponsor

Research & Scholarship

CURRENT RESEARCH AND SCHOLARLY INTERESTS

GaN Based Power Devices And Circuits

LAB AFFILIATIONS

- Srabanti Chowdhury, WBG Lab (2/1/2020)

Publications

PUBLICATIONS

- **A discussion on various experimental methods of impact ionization coefficient measurement in GaN** *AIP ADVANCES*
Ji, D., Zeng, K., Bian, Z., Shankar, B., Gunning, B. P., Binder, A., Dickerson, J. R., Aktas, O., Anderson, T. J., Kaplar, R. J., Chowdhury, S.
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- **Best Practices to Quantify Linearity Performance of GaN HEMTs for Power Amplifier Applications**
Martinez, R., Munzer, D. J., Zhou, X., Shankar, B., Schmidt, E., Wildnauer, K., Wu, B., Murmann, B., Chowdhury, S., IEEE
IEEE.2021: 85-89
- **Design of Ka-Band Doherty Power Amplifier Using 0.15 μ m GaN on SiC Process Based on Novel Complex Load Modulation**
Zhou, X., Chowdhury, S., Martinez, R., Shankar, B., IEEE
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- **On-Wafer Investigation of Avalanche Robustness in 1.3 kV GaN-on-GaN P-N Diode Under Unclamped Inductive Switching Stress**
Shankar, B., Zeng, K., Gunning, B., Lee, K., Martinez, R., Meng, C., Zhou, X., Flicker, J., Binder, A., Dickerson, J., Kaplar, R., Chowdhury, S., IEEE
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- **Distinct Failure Modes of AlGaIn/GaN HEMTs Under ESD Conditions** *IEEE TRANSACTIONS ON ELECTRON DEVICES*
Shankar, B., Raghavan, S., Shrivastava, M.

2020; 67 (4): 1567–74

- **Time Dependent Shift in SOA Boundary and Early Breakdown of Epi-Stack in AlGaIn/GaN HEMTs Under Fast Cyclic Transient Stress** *IEEE TRANSACTIONS ON DEVICE AND MATERIALS RELIABILITY*
Shankar, B., Shikha, S., Singh, A., Kumar, J., Soni, A., Gupta, S. D., Raghavan, S., Shrivastava, M.
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- **Electro-Thermo-Mechanical Reliability of Recessed Barrier AlGaIn/GaN Schottky Diodes Under Pulse Switching Conditions** *IEEE TRANSACTIONS ON ELECTRON DEVICES*
Shankar, B., Soni, A., Shrivastava, M.
2020; 67 (5): 2044-2051
- **Safe Operating Area of Polarization Super-junction GaN HEMTs and Diodes** *IEEE TRANSACTIONS ON ELECTRON DEVICES*
Shankar, B., Shrivastava, M.
2019; 66 (10): 4140–47
- **ESD Reliability of AlGaIn/GaN HEMT Technology** *IEEE TRANSACTIONS ON ELECTRON DEVICES*
Shankar, B., Raghavan, S., Shrivastava, M.
2019; 66 (9): 3756–63
- **First Observations on the Trap-Induced Avalanche Instability and Safe Operating Area Concerns in AlGaIn/GaN HEMTs** *IEEE TRANSACTIONS ON ELECTRON DEVICES*
Shankar, B., Soni, A., Chandrasekar, H., Raghavan, S., Shrivastava, M.
2019; 66 (8): 3433–40
- **ESD Behavior of AlGaIn/GaN Schottky Diodes** *IEEE TRANSACTIONS ON DEVICE AND MATERIALS RELIABILITY*
Shankar, B., Gupta, S., Soni, A., Raghavan, S., Shrivastava, M.
2019; 19 (2): 437–44
- **Positive Threshold Voltage Shift in AlGaIn/GaN HEMTs and E-Mode Operation By AlxTi1-xO Based Gate Stack Engineering** *IEEE TRANSACTIONS ON ELECTRON DEVICES*
Gupta, S., Soni, A., Joshi, V., Kumar, J., Sengupta, R., Khand, H., Shankar, B., Mohan, N., Raghavan, S., Bhat, N., Shrivastava, M.
2019; 66 (6): 2544–50
- **UV-Assisted Probing of Deep-Level Interface Traps in GaN MISHEMTs and Their Role in Threshold Voltage & Gate Leakage Instabilities**
Gupta, S., Joshi, V., Shankar, B., Shikha, S., Raghavan, S., Shrivastava, M., IEEE
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- **On the Trap Assisted Stress Induced Safe Operating Area Limits of AlGaIn/GaN HEMTs**
Shankar, B., Soni, A., Gupta, S., Sengupta, R., Khand, H., Mohan, N., Raghavan, S., Shrivastava, M., IEEE
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- **Safe Operating Area (SOA) Reliability of Polarization Super Junction (PSJ) GaN FETs**
Shankar, B., Soni, A., Gupta, S., Shrivastava, M., IEEE
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- **Trap Assisted Stress Induced ESD Reliability of GaN Schottky Diodes** *40th Electrical Overstress/Electrostatic Discharge Symposium (EOS/ESD)*
Shankar, B., Singh, R., Sengupta, R., Khand, H., Soni, A., Gupta, S. D., Raghavan, S., Gossner, H., Shrivastava, M.
IEEE.2018: 1–6
- **(Invited) Design and Reliability of GaN Power HEMT Technology** *Americas International Meeting on Electrochemistry and Solid State Science*
Shankar, B., Soni, A., Gupta, S. D., Sengupta, R., Khand, H., Mohan, N., Raghavan, S., Bhat, N., Shrivastava, M.
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- **What All We Understand About SOA Reliability of GaN HEMT** *GaN Marathon 2.0*
Shankar, B., Soni, A., Gupta, S. D., Shrivastava, M.
University of Padua.2018: 1
- **Time Dependent Early breakdown of AlGaIn/GaN Epi Stacks and Shift in SOA Boundary of HEMTs Under Fast Cyclic Transient Stress** *IEEE INTERNATIONAL ELECTRON DEVICES MEETING (IEDM)*
Shankar, B., Soni, A., Gupta, S. D., Shikha, S., Singh, S., Raghavan, S., Shrivastava, M.

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- **Trap Assisted Avalanche Instability and Safe Operating Area Concerns in AlGaIn/GaN HEMTs**
Shankar, B., Soni, A., Singh, M., Soman, R., Chandrasekar, H., Mohan, N., Mohta, N., Ramesh, N., Prabhu, S., Kulkarni, A., Nath, D., Muralidharan, R., Bhat, et al
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- **Dependence of Avalanche Breakdown on Surface & Buffer Traps in AlGaIn/GaN HEMTs**
Joshi, V., Shankar, B., Tiwari, S., Shrivastava, M., IEEE
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- **ESD Behavior of AlGaIn/GaN HEMT on Si: Physical Insights, Design Aspects, Cumulative Degradation and Failure Analysis**
Shankar, B., Soni, A., Singh, M., Soman, R., Bhat, K. N., Raghavan, S., Bhat, N., Shrivastava, M., IEEE
IEEE.2017: 361–65
- **On the ESD Behavior of AlGaIn/GaN Schottky Diodes and Trap Assisted Failure Mechanism**
Shankar, B., Sengupta, R., Gupta, S., Soni, A., Mohan, N., Bhat, N., Raghavan, S., Shrivastava, M., IEEE
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- **High-k dielectrics based field plate edge termination engineering in 4H-SiC Schottky diode** *INTERNATIONAL JOURNAL OF ELECTRONICS*
Shankar, B., Gupta, S. K., Taube, W. R., Akhtar, J.
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- **Capacitance-conductance spectroscopic investigation of interfacial oxide layer in Ni/4H-SiC (0001) Schottky diode** *PHYSICA B-CONDENSED MATTER*
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IEEE.2014
- **A Quick Method to Realize and Characterize Bimorph Cantilevers**
Prajesh, R., Shankar, B., Jain, N., Agarwal, A., Prajesh, R., Agarwal, A., IEEE
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